

# FIRST CALL FOR PAPERS

7<sup>th</sup> International Conference on Optics-photonics

Design & Fabrication

(Co-located with LENS EXPO 2010)



*“ODF '10, Yokohama”*  
*April 19–21, 2010*



**Pacifico Yokohama (パシフィコ横浜), Japan**

**Organized by**

The Optics Design Group (ODG) of OSJ / Japan

**Sponsored by**

Optical Society of Japan (OSJ; an affiliate of the Japan Society of Applied Physics)

**In cooperation with**

ICO (International Commission for Optics) • OSK (Optical Society of Korea) • COS (Chinese Optical Society) • The Optical Engineering Society, Taiwan • PIDA (Photonics Industry & Technology Development Association) • Taiwan Optics/Optronics Manufacturers' Association • The Physical Society of ROC • OSA (Optical Society of America) • SPIE (The International Society for Optical Engineering) • EOS (European Optical Society) • Applied Optics Meeting in Kansai • IEICE (The Institute of Electronics, Information and Communication Engineers) • IEIJ (The Illuminating Engineering Institute of Japan) • IIEEJ (The Institute of Image Electronics Engineers of Japan) • JIEP (Japan Institute of Electronics Packaging) • JOEM (Japan Optomechanics Association) • JOMA (Japan Optical Measuring Instruments Manufacturer's Association) • JPS (The Physical Society of Japan) • JSMBE (Japanese Society for Medical and Biological Engineering) • JSPE (The Japan Society for Precision Engineering) • LSJ (The Laser Society of Japan) • OITDA (Optoelectronic Industry and Technology Development Association) • SPSTJ (The Society of Photographic Science and Technology of Japan) • The Astronomical Society of Japan • The Color Science Association of Japan • The Spectroscopical Society of Japan



(Some of above cooperative organizations are under negotiation.)

**Paper Submission: July 20 – October 20, 2009**

<http://www.odf.jp/>

# INTRODUCTION

The 7th International Conference on Optics-photonics Design & Fabrication, “ODF'10, Yokohama,” will be held on April 19–21, 2010 at Pacifico Yokohama, Japan. Optics-photonics design and fabrication will continue to play a significantly important role in the 21st century, achieving harmony between technology and the environment. ODF'10 is intended to provide an international forum for original paper presentations and discussions of optics-photonics design- and fabrication-related technological and scientific topics, including theory, design, fabrication, testing, applications and others.

Collaboration and Competition make progress.

Join us at ***ODF'10, Yokohama!***

LENS EXPO 2010 will also be held April 21–23 at the conference site. For more information please visit the website below.

<http://www.optronics.co.jp/en/lens/>

## SCOPE OF THE CONFERENCE

ODF'10 is an international forum for engineers and scientists in the field of Optics-photonics Design and Fabrication to exchange their ideas and achievements with the goal of future mutual progress. The conference will consist of sessions on optics-photonics design, simulation, optical components, optical systems, and optical technology. These sessions will cover the fields of optical theory, fabrication and testing, software, DOEs, micro-optics, nano-optics, photonic crystals, near-field optics, thin films, waveguides, MEMS, lasers, fiber communications, information optics, optical storage, optical lithography, microscopy, displays, bio-medical optics and others. A special session on “Reflection Control by Nano-structures” is also planned.

## PREPARATION OF ABSTRACTS AND MANUSCRIPTS

A limited number of original papers will be accepted for presentation. Authors are required to submit a 35-word abstract and a 2-page manuscript. Papers must be submitted online. Please see the ODF'10 website for details of the submission procedure. Authors are required to agree to copyright transfer by including a completed form when submitting abstracts and manuscripts. The form can be downloaded from the conference website.

## ● 35-word Abstracts

Abstracts should be up to 35 words in an ASCII text file. Please avoid the use of scientific and engineering symbols in the abstract. Abstracts that are longer than 35 words will be shortened by the program committee. If your paper is accepted, the abstract will appear in the Advance Program.

## ● 2-page Manuscripts

2-page camera-ready manuscripts including text, figures, tables and references must be typed single-spaced on A4 or letter size pages with the title followed by the author's name, affiliation, and address. Accepted papers will be published in the Technical Digest of the conference. For the layout of the manuscript, please see the Guidelines on the ODF10 website (to be opened this May).

## ● Abstract & Manuscripts will be accepted: July 20 to October 20, 2009

For inquiries, please contact:

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The presentation schedule will be determined after the program committee has reviewed the papers. Authors will be notified by January 2010 whether their papers have been accepted. Notification will be sent to the author listed first by e-mail or letter. Note that it will be the author's responsibility to obtain any necessary and appropriate clearances from his/her affiliated organization.

## **ADDITIONAL INFORMATION**

### **● Post-Deadline Papers**

Detailed information will be announced in the Final Call for Papers.

### **● ODF'10 Special Issue of OPTICAL REVIEW**

The presented papers can be resubmitted and published in the ODF'10 special issue of OPTICAL REVIEW, which is the English-language journal of the Optical Society of Japan (OSJ). Application forms for the special issue will be distributed on site.

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## **For information mail**

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**Additional information (Final Call for Papers, Advance Program) will be sent on request.**

Please send e-mail or fax the information request form to ODF '10 Secretariat.

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